



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

6/EOT(1)
P. Alab
1-21-03

Application No.: 10/056,926

Confirmation No.: 4011

First Named Inventor: Justin F. Gaynor

Filing Date: January 24, 2002

Group Art Unit: 2812

Examiner: Thanhha S. Pham

Atty. Docket No.: M-12018 US

Title: In-Situ Treatment Of Low-K Films With A Silylating Agent After Exposure To Oxidizing Environments

Assignee: Novellus Systems, Inc.

San Francisco, California
January 8, 2003

COMMISSIONER FOR PATENTS
Washington, D. C. 20231

PETITION FOR EXTENSION OF TIME

Sir:

Applicant respectfully petitions for a one-month extension of time within which to respond to the Office Action mailed November 25, 2002, such extension allowing the undersigned until January 25, 2003 to respond.

Please charge the amount of \$110.00 against Deposit Account 19-2386 as set forth in the enclosed transmittal letter.

EXPRESS MAIL LABEL NO:

EV 259 164 146 US

Respectfully submitted,

K. Alison de Runtz

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Attorney of Record
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